

## **WAVEGUIDE TO LAMINATED WAVEGUIDE TRANSITION AND METHODOLOGY**

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### **RELATED APPLICATION(S)**

**[0001]** The present patent application is related to and claims the benefit of priority from commonly-owned U.S. Provisional Patent Application No. 60/395,952, filed on July 13, 2002, entitled "Waveguide to Laminated Waveguide Transition and Methodology", which is hereby incorporated by reference in its entirety for all purposes.

### **TECHNICAL FIELD**

**[0002]** The present invention relates to apparatus and/or methodology involving transitioning an electromagnetic wave between two waveguides. Embodiments of the present invention are especially suitable for use where there is a scale mismatch between the two waveguides, for example, when the two waveguides include materials in their interior that have different (finite) dielectric constants.

### **BACKGROUND OF THE INVENTION**

**[0003]** Metal waveguides and laminated waveguides are examples of transmission lines that transport electromagnetic energy. A metal waveguide is usually constructed as a metal tube in which an electromagnetic signal wave propagates along the interior of the tube by reflecting back and forth between the walls of the waveguide. A metal waveguide can be filled either with air or dielectrics and its cross-section is generally circular or rectangular.

**[0004]** Metal waveguides have a critical wavelength for passage of signals within. The wavelength is determined by the geometry and the size of the waveguide. Only those signals whose wavelength is shorter than the critical wavelength can propagate in the

waveguide. At high microwave frequency, particularly the millimeter-wave frequency, the metal waveguide has proven to be the transmission line with minimum signal loss.

[0005] A laminated waveguide is a derivative of the metal waveguide. Instead of using a solid metal tube, a typical laminated waveguide is composed of a dielectric substrate, a pair of main conductive layers deposited on the upper surface and the lower surface of the dielectric substrate, a plurality of through conductors such as filled vias extending in a thickness direction in the dielectric substrate so that the through conductors electrically connect the pair of the main conductive layers and a number of sub-conductor strip layers, which are embedded and electrically connected to the vias within the dielectric substrate. A laminated waveguide constructed in the said way has reasonably good transmission characteristics of high-frequency signal and has advantages in cost of production and in ability to be integrated with circuits.

#### BRIEF SUMMARY OF EMBODIMENTS OF THE INVENTION

[0006] It is advantageous in a system to have coexisting modules that use different types of waveguides, for example, waveguides that differ from each other in physical scale. For example, the different types of waveguides may respectively include materials in their interior that have dielectric constants that differ from one another. For example, one type of waveguide may be a laminated waveguide, and the other type may be a metal waveguide. What is needed are methods and apparatuses that allow transition between different types of waveguides.

[0007] According to some embodiments of the present invention, there is a waveguide to laminated waveguide transition integrated with a multi-layer substrate package.

[0008] According to some embodiments of the present invention, there is a waveguide to laminated waveguide transition in an integrated functional module that can be easily fabricated.

**[0009]** According to some embodiments of the present invention, there is a waveguide to laminated waveguide transition that can be inexpensively fabricated in high volume production.

**[0010]** According to some embodiments of the present invention, there is a waveguide to laminated waveguide transition that is effective at millimeter-wave and high microwave frequencies.

**[0011]** According to some embodiments of the present invention, there is an apparatus through at least a portion of which electromagnetic waves are to be propagated. The apparatus comprises: a structure, hereinafter referred to as boundary structure, that defines at least an interior, hereinafter referred to as transition interior, the boundary structure including electrically-conductive materials, the boundary structure further defining a first and a second opening to the transition interior, the first opening configured to be open toward an interior, hereinafter referred to as first interior, of a laminated waveguide, hereinafter referred to as first waveguide, and the second opening configured to be open toward an interior, hereinafter referred to as second interior, of a second waveguide, the second interior being defined by an electrically-conductive structure of the second waveguide, whereby an electromagnetic wave is capable of being propagated, for use, via the transition interior, from one of the first interior and the second interior to the other of the first interior and the second interior, wherein content of the first interior has a dielectric constant that differs from a dielectric constant of content of the second interior, and the second waveguide is made not via lamination on a same substrate as the first waveguide.

**[0012]** According to some embodiments of the present invention, there is a method for transitioning electromagnetic waves from a first waveguide to a second waveguide, the first waveguide having a first interior defined by an electrically-conductive first structure, the second waveguide having a second interior defined by an electrically-conductive second structure, content of the first and second interiors having mutually-different dielectric constants, the method comprising: accepting an electromagnetic wave directly from the first interior into an interior, hereinafter referred to as transition interior,

of a transition, the transition interior being defined by an electrically-conductive structure of the transition, the transition interior being open to the first and second interiors; conveying the electromagnetic wave directly from the transition interior into the second interior.

[0013] According to some embodiments of the present invention, there is a method for producing a waveguide-to-waveguide transition. The method comprises fabricating an electrically-conductive structure, hereinafter referred to as transition boundary structure, the transition boundary structure to define an interior, hereinafter referred to as transition interior, including a first and a second opening to the transition interior, wherein, at least after the transition is deployed for use, the first opening is to open toward a first interior of a first waveguide and the second opening is to open toward a second interior of a second waveguide, the first and second interiors to comprise mutually-different materials having mutually-different dielectric constants.

#### BRIEF DISCRIPTION OF THE DRAWINGS

[0014] Fig.1 is a schematic 3D cut-away perspective view showing a first embodiment of the integrated transition with a rectangular air filled waveguide flange of the present invention.

Fig.2 is a schematic plan view showing the upper main conductor layer 1 in Fig.1.

Fig.3 is a schematic plan view showing the lower main conductor layer 4 in Fig.1, on which aperture 5 is laid.

Fig.4 is a schematic plan view showing circuit pattern of sub-conductor layers 2 in Fig.1.

Fig.5 is a schematic plan view showing circuit pattern of sub-conductor layers 3 in Fig.1.

Fig.6 is a schematic section view of the first embodiment of invention thereof along the line A-A' in Fig. 1.

Fig.7 is a schematic version of Fig. 4 with labels and markings to illustrate equivalent resonators within the first embodiment presented in Fig.1.

Fig.8 is an equivalent circuit topology to the transition according to the first embodiment presented in Fig.1.

Fig.9 is a schematic 3D perspective cut-away view of a second embodiment of the present invention.

Fig.10 is a schematic 3D perspective cut-away view of a third embodiment of the present invention.

Fig.11 is a graph that shows simulated and measured reflection performance of an implementation of the embodiment presented in Fig. 1.

Fig.12 is a schematic 3D perspective cut-away view of a fourth embodiment of the present invention.

#### DETAILED DESCRIPTION OF EMBODIMENTS OF THE INVENTION

**[0015]** The description above and below and the drawings of the present document focus on currently preferred embodiments of the present invention and also describe some exemplary optional features and/or alternative embodiments. The description and drawings are for the purpose of illustration and not limitation.

**[0016]** In many commercial and military systems operating in millimeter wave frequency range, such as vehicular and military radars and various types of communication systems, in order to minimize attenuation and maintain high efficiency and sensitivity, waveguide transmission line is used as the major means for distributing and collecting the high frequency signal among various modules such as antenna array and front end modules.

**[0017]** Conventional solutions using solid metal waveguide system entail the use of expensive mechanical machining. With modern advances in multi-layer manufacturing technology and low loss materials, it is advantageous, especially in the newly developed millimeter-wave Local Multipoint Distribution System (LMDS) and anti-collision radar systems for automobiles, to use integrated laminated waveguide instead of metal waveguide to minimize size and cost. Therefore, it will be advantageous in a system to have coexisting both integrated modules that use laminated waveguide as main embedded transmission line and also modules that are interfaced with metal waveguide. Thus, a key

device in connecting the two different types of modules in such systems is a metal waveguide to laminated waveguide transition that provides low signal loss in a broad frequency band.

[0018] Due to the high dielectric constant in the substrate (e.g., about 7 to 20), the transversal dimension of a laminated waveguide, which determines the signal frequency down the transmission line, can be less than half of the transversal dimension of the metal waveguide. This large dimension mismatch causes a great difficulty to design a low loss transition between the two types of waveguide, particularly a broadband transition. There are, at least, three attractive features to have a broad frequency bandwidth transition: (1) being able to handle broadband signal including transmitted and received bands; (2) being able to accommodate large mechanical tolerance to improve the yield in high volume production and (3) providing low insertion loss.

[0019] According to some embodiments of the present invention, there is a waveguide to integrated laminated waveguide transition that is a directly fabricated and hermetically sealed packaging structure, which may also connect the conventional waveguide equipment, through the integrated laminated waveguide, to certain functional apparatus, such as antenna array, operating at millimeter-wave or microwave frequencies.

[0020] A circuit system integrated with laminated waveguide can be produced by a laminating technology, such as Low Temperature Co-fired Ceramics (LTCC) technology, and has excellent productivity.

[0021] According to some embodiments of the present invention, there is a broadband and compact integrated transition between laminated waveguide and metal waveguide. The novel transition adopts the concept of multi-parallel-coupled 2-pole resonator filter to create two resonant poles in the pass-band. A Ka band embodiment (e.g., at 29 GHz) shows a very low loss over a broad (e.g., better than 8.5%) frequency bandwidth.

[0022] According to some embodiments of the present invention, there is a waveguide to laminated waveguide transition that includes a number of sub-circuits.

Laminated waveguides comprise single or multiple dielectric substrate layers, a pair of main conductive layers laminated on the upper surface and the lower surface of the dielectric substrate layers. A plurality of via-holes extending in a thickness direction in the dielectric substrate layers so that they electrically connect the pair of the main conductive layers to form conductive walls. A number of sub-conductive layers, which are embedded in the dielectric substrate parallel to the main conductive layers and electrically connected to the via-holes to enhance the conductive walls, are optional to provide further reduction of the leakage of electromagnetic signals. The conductive layer on the lower surface that faces to metal waveguide is selectively patterned such that conductive material is removed over the metal waveguide aperture.

**[0023]** According to some embodiments of the present invention, the integrated transition comprises of multi-parallel inter-coupled resonator chains formed by said through conductive partition walls. Partial metal strip and correlative through conductors in conductive partition walls are removed to help provide matching to a metal waveguide. Each resonator chain comprises two resonators connected in series. One resonator in a resonator chain (which is called type I resonator hereinafter) is a section of laminated waveguide, whose lower conductor layer is partially removed, is shorted at one end and connected with the other resonator (which is called type II resonator hereinafter); Both type I and type II resonators are quasi half wavelength resonator resonating around the working frequency; the resonant frequency is controlled by the location of its shorting wall. Type II resonator consists of a section of laminated waveguide and a junction of the laminated waveguide branch divider connecting with the main laminated waveguide. The junction essentially is a part of a multi-branch divider junction used to combine and distribute electromagnetic energy to each laminated waveguide branch composing a resonator chain. The junction provides an appropriate termination to each of the resonator chains and a slight inter resonator coupling.

**[0024]** The working mechanism of the transition can be explained, for example, by the concept of a multi- parallel inter-coupled 2-pole resonator filter, which creates two resonant poles in the pass-band. An equivalent circuit model is given in Fig.8 to interpret the concept in conjunction with its 3D structure shown in Fig.1.

**[0025]** According to some embodiments of the present invention, the waveguide to laminated waveguide transition and associated multi-layer (such as LTCC) module are suitable for use with microwave and millimeter-wave frequencies (approximately 20-100 GHz) with very low insertion loss. The multi-layer module offers routing of DC and microwave/millimeter-wave signals through the layers inside the module thereby minimizing the size of the module. The associated multi-layer module can be a passive integrated front-end module such as filters, diplexers, and antenna arrays, or an active integrated module consisting of monolithic millimeter-wave integrated circuit (MMIC) and laminated waveguide network. As a result, applications which require an interface of conventional metal waveguide to integrated laminated waveguide modules for high frequency signal transmission can readily make use of the low cost, high performance metal waveguide to laminated waveguide transition provided by some embodiments of the present invention.

**[0026]** The laminated waveguide concerning some embodiments of the present invention comprises a plurality of through conductors such as via-holes disposed at carefully designed intervals, a plurality of sub-conductor layer deposited between dielectric layer of a dielectric substrate and the upper and the lower main conductor layers so as to electrically connect between through conductors within the dielectric substrate formed by laminated dielectric layer. The metal waveguide concerning the some embodiments is either air filled or dielectric filled waveguide separated from the laminated dielectric layers and will be called metal waveguide hereinafter. The integrated module and the waveguide concerning to the invention can be jointed, for example, by soldering or conductivity adhesive or the like. In many envisioned applications, the laminated waveguide's interior is filled with material having a dielectric constant that is greater than that of material in the interior of a metal waveguide. For example, a metal waveguide may be filled with air, which has a far lower dielectric constant (one) than dielectric materials in a laminated waveguide. For nonlimiting examples, the difference in dielectric constant may be more than three, or more than seven, or more than an even greater numerical difference.



[0027] Fig.1 is a schematic perspective cut-away view of a first embodiment of the transition of the present invention. The transition is integrated within a multi-layers ceramic substrates module *10*, and connected with metal waveguide *11*.

[0028] The laminated waveguide transition in Fig.1 consists of a dielectric substrate formed by a plurality of dielectric layers, main conductive layers *1* and *4* deposited on the upper and the lower surface of the dielectric substrates, a plurality of sub-conductor layers *2* and *3*, deposited between the laminated dielectric layers composing the dielectric substrate, and a number of through conductors, filled via-holes *6*, so as to electrically connect the main conductor layers *1* and *4*, and the sub-conductor layers *2* and *3* to form a 3D waveguide resonator structure in dielectric substrate. The interval space between via-holes inside the through conductor wall is predetermined by the working frequency. The number of dielectric layers is determined by the size of laminated waveguide and thickness of each dielectric layer.

[0029] An aperture *5* is deposited on the lower main conductor layer *4*. Line *B-B'* is parallel to and in proximity of the midline of aperture *5* in narrow sidewall direction. The conductive wall along line *A-A'* is called partition wall thereafter and denoted as *8* in Fig.1. The matching aperture *9* is on the partition wall *8*. The conductive wall *7* parallel to the line *B-B'* in Fig.1 is a shorting wall to the laminated waveguide resonators.

[0030] Thus, the features *1*, *4*, *2*, *3*, and *6* of Fig. 1 are an example of a structure that defines an interior of the transition of Fig. 1. Moving in the interior of the transition, in a direction opposite the conductive shorting wall *7*, leads to an interior of a laminated waveguide. The transition of Fig. 1 includes an opening, e.g., defined by the sidewalls and the layers *1* and *4*, that opens into the interior of the laminated waveguide. The aperture *5* opens toward an interior of the metal waveguide *11*.

[0031] Fig.2 schematically illustrates the upper main conductor layer *1* in Fig.1. The upper main conductor layer *1* is fully moralized in transition circuit region and is connected with next sub-conductor layer by array of via-hole *6*. In Fig.1 the upper layer *1* is optionally the upper exposed surface of the dielectric substrate.

[0032] Fig.3 schematically shows a plan view of layer 4. Aperture 5 is laid on main conductor layer 4 and not covered by conductor. The electromagnetic energy is transmitted via aperture 5 between metal waveguide 11 and laminated waveguide inside the multi-layer module 10. The metal waveguide flange 11 beneath the dielectric substrate showing in Fig.1 is soldered on the main conductor layer 4 with the inside aperture of metal waveguide aligned with the edge of aperture 5.

[0033] The sub-conductor layers of the transition of the embodiment of Fig.1 have the same circuit pattern and are electrically connected by an array of via-hole 6 to form the outside wall, partition wall and shorting wall. To construct the matching aperture 9 on the partition wall 8, partial metal strips on sub-conductor layer 3 and correlative via-holes are removed.

[0034] Fig. 4 schematically shows the circuit pattern of the sub-conductor layers 2 in Fig.1, and Fig.5 schematically shows the circuit pattern of the sub-conductor layers 3 in Fig.1. Owing to the existence of the aperture 9, the circuit pattern on sub-conductor layers 3 is different from that of the sub-conductor layers 2 in Fig.1 of the first embodiment. As shown in Fig.5, the metal strips of partition wall 8 on a plurality of sub-conductor layers 3 became two segments separated by a non-metal space to form said matching aperture 9.

[0035] Fig. 6 schematically illustrates the section view of the first embodiment of invention thereof along the line  $A-A'$  in Fig.1. The height of aperture 9 in Fig. 6 is denoted as  $h$ , and can be adjusted by controlling the amount of layers of sub-conductor layer 3 as shown in Fig.5.

[0036] Shield by the pair of main conductor layers and through conductive wall, 4 quasi-resonators composing two resonator chains are formed inside layered dielectric substrate. Fig.7 schematically illustrates the boundary and name to the four equivalent resonators in the transition of the first embodiments of the invention. From line  $B-B'$  to shorting wall 7 in Fig.7, a pair of said type I resonators denoted as  $R1$  and  $R2$  are constructed. The other pair of resonators denoted as  $R3$  and  $R4$  are formed by the laminated waveguide section between  $B-B'$  and  $C-C'$  shown in Fig.7.  $R3$  and  $R4$  are said

type II resonators.  $R1$  and  $R3$  form one resonator chain, and  $R2$  and  $R4$  form another resonator chain. The two resonator chains are separated by the partition wall 8 and are coupled with each other via the aperture 9 and the Y junction connecting to the main laminated waveguide  $R5$ .

[0037] Resonator loops  $R1\sim R4$  in Fig.8 represent the resonators defined in Fig.7.  $R0$  and  $R5$  denote the metal waveguide and laminated waveguide region, respectively. The coupling coefficient  $M_{01}$ ,  $M_{02}$ ,  $M_{03}$  and  $M_{04}$  denote the coupling between the four resonators and metal waveguide via aperture 5. The function of the Y branch laminated waveguide power divider is represented as coupling coefficient  $M_{35}$  and  $M_{45}$ . The mutual coupling coefficient  $M_{12}$  and  $M_{34}$  denote the effects of the matching aperture 9 and the Y junction. The last two coupling coefficient  $M_{13}$  and  $M_{24}$  represent the connection between two types of resonators.

[0038] By adjusting the coupling coefficient between resonators, an expected reflection and transmission performance can be obtained. The coupling coefficient can be controlled by the position of the shorting wall 7, height of aperture 9 and the dimension of Y branch laminated waveguide power divider. According to the equivalent circuit, the filter coupling matrix module can be employed to synthesize the required performance of the transition of an embodiment of the present invention.

[0039] Known from the equivalent circuit showing in Fig.8, the divider structure is employed to provide a function of creating in-phase equal amplitude and low insertion loss coupling. Therefore, any kind of H plan waveguide branch or divider structure can be employed in an embodiment of the present invention.

[0040] Fig.9 schematically shows a second embodiment of the invention, which is an example of using a T type divider structure instead of a Y branch structure.

[0041] For some high permittivity applications, the broadside size of laminated waveguide might be much smaller than half of the broadside size of the metal waveguide. A multi-parallel inter-coupled resonator chain structure can be employed by an embodiment of the present invention.

[0042] Fig.10 is a schematic perspective cut-away view showing a third embodiment of the transition of the invention. Features in Fig. 10 are numbered from 1-13. Thus, the numbers 1-11, which were used in earlier drawings, are being reused for convenience, because they refer to elements of Fig. 10 that are similar to elements from previous drawings. However, the elements of Fig. 10 are not meant to be identical to elements from earlier drawings, as is apparent from visual comparison of the drawings.

[0043] In Fig. 10, a triple parallel inter-coupled resonator chain structure is presented in the third embodiment of the invention. Separated by two conductive partition walls 8 and 12, three resonator chains are formed inside the transition shown in Fig.10. The broadside size of the laminated waveguides in Fig.10 is approximately one third of the metal waveguide broadside size. A three-branch Y type power divider is used as the junction between the main laminated waveguide and three side-by-side laminated waveguide sections in the embodiment. The coupling between adjacent resonator chains is produced by matching aperture 9 and 13 on the two partition walls and the Y junction.

[0044] Known from the equivalent circuit, the dimension of the aperture on the lower main conductive layer also can be adjusted to achieve appropriated coupling coefficient.

[0045] One transition explained in the first embodiment shown in Fig.1 was fabricated. The designed center frequency of the transition of an embodiment of the present invention was 29GHz. The transversal dimensions of the extend waveguide and laminated waveguide are 280 by 140 mils<sup>2</sup> and 140 by 35.2 mils<sup>2</sup>, respectively. Low temperature co-fire ceramics (LTCC) substrate whose relative permittivity  $\epsilon_r = 7.5$ , dielectric loss  $\tan\sigma = 0.002$ , and thickness = 4.4 mils was used as the dielectric materials of layers and silver alloy was used for metallization. Eight dielectric layers and nine conductive layers were used. The matching aperture dimensions are 140 mils in length and 13.2 mils in height  $h$ .

[0046] Fig.11 shows the simulated and the measured results of the fabricated prototype of a particular implementation of the first embodiment of the invention. The horizontal axial represents a frequency (GHz), the vertical axis represents an amount of

reflection (dB). Defined at  $-15\text{dB}$  reflection, the measured bandwidth of the transition is above  $2.5\text{GHz}$  ( $8.6\%$  with respect to the center frequency  $29\text{GHz}$ ). Obtained from measured result to a fabricated back-to-back configuration of the transition pair, the insertion loss of the single transition is lower than  $0.45\text{dB}$  over the whole  $2.5\text{GHz}$  bandwidth with a section of 120 mils laminated waveguide and a 150 mils thick metal waveguide flange.

[0047] A designer who wishes to design a particular implementation of an embodiment of the present invention would select the various dimensions and parameters of the embodiment of the present invention in order to obtain desired characteristics. According to conventional design practice, conventional electromagnetic simulation software can be used to select the various dimensions and parameters. For example, a conventional full-wave finite-element method 3-dimensional electromagnetic simulator, may be used. Examples of embodiments of the present invention, as well as use of simulation to select dimensions and parameters, are discussed in an article by the present inventors, Yong Huang and Ke-Li Wu, "A Broad-Band LTCC Integrated Transition of Laminated Waveguide to Air-Filled Waveguide for Millimeter-Wave Applications", in IEEE Transactions on Microwave Theory and Techniques, Vol. 51, No. 5, May 2003, which is hereby incorporated by reference in its entirety for all purposes.

[0048] Fig.12 is a schematic 3D perspective cut-away view of a fourth embodiment of the present invention. A single laminated waveguide resonator chain structure that contains more than one resonator is presented in Fig.12. For example, one resonator in the resonator chain is constructed of a perturbing conducting wall 4 and a shorting conducting wall 7; the other resonator in the chain is formed by a perturbing conducting wall 3 and the perturbing conducting wall 4. The laminated waveguide and the resonator chain are constructed by grid like conducting walls on two sides and the top and bottom surfaces of the substrate, except the coupling aperture 5 on the bottom surface. Coupling aperture 5 is smaller than the aperture of metal waveguide 23, shown in dashed lines. The perturbing conducting walls 21 and 22 are introduced to control the couplings between laminated waveguide 20 and resonators, respectively. The size of coupling

aperture 5 controls the coupling between metal waveguide and the resonators in the substrate.

[0049] Specific example embodiments of the present invention are discussed below.

[0050] Example embodiment 1: A waveguide to laminated waveguide transition comprises:

- a dielectric substrate;
- a pair of main conductive layers deposited on the upper dielectric layer surface and the lower dielectric layer surface of the dielectric substrate and said upper main conductive layer and lower conductive layer;
- a plurality of conductors walls comprising:
  - a plurality of through conductors, such as via-holes, extending in a thickness direction in the dielectric substrate layers; and
  - a number of optional sub-conductor layer paralleled to the two main conductive layers and deposited between dielectric layer of a dielectric substrate so that electrically connected to the through conductors to form the conductive walls;
- a plurality of laminated waveguide comprising:
  - the upper and the lower main conductor layers working as broadside walls; and
  - two said conductor walls as sidewalls so that electrically connecting the upper and the lower main conductor layers to form a waveguide structure inside the dielectric substrate;
- an aperture laying on one of the said main conductive layers so that the energy is transferred between the region inside the dielectric substrate and the outside via the aperture;
- a multi-parallel inter-coupled resonator chain structure comprising:
  - a transition region over the said aperture covered by said two main conductive layers, encircled by said conductive walls and terminated by a section of laminated waveguide ;
  - at least one conductive wall called partition wall separating the said region into at least two parts said sub laminated waveguides;

at least one segment of conductor wall shorted at one end of the said sub laminated waveguide, which is said shorting wall, and the other end of the sub laminated waveguide terminated by a multi-branch junction; here, the shorting wall to each sub laminated waveguide can be disposed on different plane;

a multi-branch structure connecting with the other end of the said sub laminated waveguide and distributing the energy from said laminated waveguide to said sub laminated waveguides or combining the energy from sub laminated waveguides to laminated waveguide;

at least one aperture called matching aperture located on each the said partition wall to adjust the matching condition looking from the metal waveguide side; and

a waveguide extension having a conductive tube carrying the RF energy.

[0051] Example embodiment 2: The waveguide to laminated waveguide transition of example embodiment 1, wherein said waveguide extension comprises of waveguide flange soldered on the system ground and aligned with said aperture, or a plurality of plated or conductor filled through via-holes, or a waveguide formed by an aperture in a base of conducting material.

[0052] Example embodiment 3: The waveguide to laminated waveguide transition of example embodiment 2, wherein said dielectric layers comprise low temperature co-fired ceramics (LTCC).

[0053] Example embodiment 4: The waveguide extension of example embodiment 1 has cross section of either rectangular shape supporting TE<sub>10</sub> mode as dominant mode or circular shape supporting TE<sub>11</sub> mode as dominant mode.

[0054] Example embodiment 5: The performance of the circuit module of example embodiment 1 can be adjusted by said aperture on main conductive layer, said matching aperture, said the distance from said shorting wall to center of said aperture and said multi-branch junction.

[0055] Example embodiment 6: A transition circuit module comprising:  
a dielectric substrate;

a pair of main conductive layers deposited on the upper dielectric layer surface and the lower dielectric layer surface of the dielectric substrate and said upper main conductive layer and lower conductive layer;

a plurality of conductors walls comprising:

a plurality of through conductors, such as via-holes, extending in a thickness direction in the dielectric substrate layers; and

a number of optional sub-conductor layer paralleled to the two main conductive layers and deposited between dielectric layer of a dielectric substrate so that electrically connected to the through conductors to form the conductive walls;

a plurality of laminated waveguide comprising:

the upper and the lower main conductor layers working as broadside walls; and

two said conductor walls as sidewalls so that electrically connecting the upper and the lower main conductor layers to form a waveguide structure inside the dielectric substrate;

an aperture laying on one of the said main conductive layers so that the energy is transferred between the region inside the dielectric substrate and the outside via the aperture;

a multi-parallel inter-coupled resonator chain structure comprising:

a transition region over the said aperture covered by said two main conductive layers, encircled by said conductive walls and terminated by a section of laminated waveguide ;

at least one conductive wall called partition wall separating the said region into at least two parts said sub laminated waveguides;

at least one segment of conductor wall shorted at one end of the said sub laminated waveguide, which is said shorting wall, and the other end of the sub laminated waveguide terminated by a multi-branch junction; here, the shorting wall to each sub laminated waveguide can be disposed on different plane;

a multi-branch structure connecting with the other end of the said sub laminated waveguide and distributing the energy from said laminated waveguide to said sub laminated waveguides or combining the energy from sub laminated waveguides to laminated waveguide;



at least one aperture called matching aperture located on each the said partition wall to produce inter coupling between adjacent parts; and

a metal base supporting said dielectric substrate, said metal base having an aperture aligned with the said aperture on the said main conductive layer.

**[0056]** Example embodiment 7: The circuit module of example embodiment 6, wherein said metal base, said lower main conductive layer and said dielectric substrate, comprise a hermetically sealed package.

**[0057]** Example embodiment 8: The circuit module of example embodiment 6, further comprising at least one additional transition from laminated waveguide to another form of transmission line, e.g., a microstrip line or stripline, e.g., underneath aperture 9 of Fig.1.

**[0058]** Example embodiment 9: The circuit module of example embodiment 8, further comprising at least one processing circuit connected to said microstrip line or stripline.

**[0059]** Example embodiment 10: The circuit module of example embodiment 9, further comprising a heat sink located in proximity to said at least one processing circuit.

**[0060]** Example embodiment 11: The circuit module of example embodiment 10, wherein said heat sink comprising a plurality of via-holes connection the ground plane under the said processing circuit and said the lower main conductive layer, which said the metal base soldering with.

**[0061]** Example embodiment 12: The transition circuit module of example embodiment 6 is a part of an integrated antenna module.

**[0062]** Example embodiment 13: The transition circuit module of example embodiment 6 is a part of integrated module comprising an MMIC.

**[0063]** Example embodiment 14: The transition circuit module of example embodiment 6 is used in a module incorporating laminated waveguide filters and a diplexer.

[0064] Example embodiment 15: The waveguide extension of example embodiment 6 has cross section of either rectangular shape supporting TE<sub>10</sub> mode as dominant mode or circular shape supporting TE<sub>11</sub> mode as dominant mode.

[0065] Example embodiment 16: The performance of the circuit module of example embodiment 6 can be adjusted by said aperture on main conductive layer, said matching aperture, said the distance from said short-wall to center of said aperture and said multi-branch junction.

[0066] Throughout the description and drawings, example embodiments are given with reference to specific configurations. It will be appreciated by those of ordinary skill in the present art that the present invention can be embodied in other specific forms without departing from the spirit and scope of the present invention. Changes and modifications are to be understood as included within the scope of the present invention. The scope of the invention is not limited merely to the specific example embodiments of the foregoing description but rather is indicated by the appended claims.